

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q62193

Kenichiro SATO, et al.

Appln. No.: 09/729,953

Confirmation No.: 7258

Group Art Unit: 1752

Filed: December 6, 2000

Examiner: John S Y CHU

For: POSITIVE TYPE PHOTORESIST COMPOSITION

**RESPONSE UNDER 37 C.F.R. § 1.114(c) AND STATEMENT OF SUBSTANCE OF
INTERVIEW**

MAIL STOP RCE

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Sir:

In response to the Office Action dated September 19, 2006, please consider the remarks as submitted herewith on the accompanying pages. A Petition and payment for a one month extension of time are being filed herewith, making this Response due on or before January 19, 2007. A Request for Continued Examination is being filed concurrently, also.

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